AMENDMENTS TO THE CLAIMS

The following listing of claims will replace all prior versions and listings of claims in the application.

LISTING OF CLAIMS

1. (Previously Presented) A manufacturing method for an electrooptic device that includes a plurality of pixels, a reflecting section that reflects light, and a transmitting section provided in the pixel that allows light to pass therethrough, the manufacturing method comprising the step of:

forming a reflective layer at the reflecting section; and

forming a colored layer that overlaps the reflective layer in the pixel, the colored layer is exposed using a mask, the colored layer has an opening with a two-dimensional shape having no corner and is formed at the reflecting section in at least some of the pixels, the mask has a pattern having an asymmetrical, two-dimensional shape with no corner.

2. – 3. (Cancelled)

4. (Previously Presented) A manufacturing method for an electrooptic device that includes a plurality of pixels, a reflecting section that reflects light, and a transmitting section provided in the pixel that allows light to pass therethrough, the manufacturing method comprising the step of:

forming a reflective layer at the reflecting section; and

forming a colored layer that is overlapping the reflective layer in the pixel, the colored layer is exposed using a mask;

the colored layer has an opening that has a polygonal two-dimensional shape with all interior angles larger than 90 degrees, the colored layer is formed at the reflecting section in at least some of the pixels;

the mask has a pattern that has a polygonal two-dimensional shape that is asymmetrical and has all interior angles larger than 90 degrees.

5. (Cancelled)

6. (Cancelled)

7. (Previously Presented) A manufacturing method for an electrooptic device that includes a plurality of pixels, a reflecting section that reflects light, and a transmitting section provided in the pixel that allows light to pass therethrough, the manufacturing method comprising the step of:

forming a reflective layer at the reflecting section; and

forming a colored layer that is overlapping the reflective layer in the pixel, the colored layer is exposed using a mask;

the colored layer has an opening that is formed at the reflecting section in at least some of the pixels, the opening has a shape such that the positions of intersections of respective normals to two arbitrary tangents on an outer periphery of the opening disperse;

the mask has a pattern with an asymmetrical two-dimensional shape such that points of intersection of respective normals to two arbitrary tangents on an outer periphery of the opening are dispersed.

8. – 11. (Cancelled)

12. (Previously Presented) An electronic device, comprising:

an electrooptic device manufactured by the manufacturing method for an electrooptic device as recited in Claim 1; and

a control means for controlling the electrooptic device.

13. (Cancelled)

14. (Previously Presented) A manufacturing method for an electrooptic device that includes a plurality of pixels and a reflecting section that reflects light and a transmitting section that allows light to pass therethrough provided in the pixel, the manufacturing method comprising the steps of:

forming a reflective layer at the reflecting section; and

forming a colored layer by exposing the colored layer using a mask;

the colored layer overlaps the reflective layer in the pixel and the colored layer has an opening; and

the mask has a pattern with an asymmetrical, two-dimensional shape with no corner.

15. – 17. (Cancelled)